

Hafnium Oxide (HfO₂) Sputtering Targets

Material Type	Hafnium Oxide	Theoretical Density (g/cc)	9.68
Symbol	HfO ₂	Z Ratio	**1.00
Color/Appearance	White, Crystalline Solid	Sputter	RF, RF-R
Melting Point (°C)	2,758	Max Power Density	20
Purity:	99.95%, 99.99%,	(Watts/Square Inch)	
		Type of Bond	Indium
		Export Control (ECCN)	1C231